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## Advanced Oxidation Processes for the Removal of Contaminants of Emerging Concern from Wastewater

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Deadline for manuscript submissions:

**closed (31 December 2020)**

### Message from the Guest Editors

Advanced oxidation processes (AOPs) such as photocatalytic processes, electrochemical processes, ozonation, Fenton, etc. are considered as a good option for the treatment of wastewater polluted with presence of contaminants of emerging concern (CECs), because they are a very efficient technology for the removal of a great variety of organic pollutants thanks to the massive generation of hydroxyl radicals and many other mediated oxidants produced at high concentrations on the anode surface. The robustness and high efficiency of this approach has been checked in many works for the treatment of water and wastewater polluted with different organic compounds, and now scientific effort is focused on its application for the removal of CECs. Thus, this Special Issue seeks to publish interesting research works that demonstrate high-efficiency AOPs for the treatment of water and wastewater polluted with CECs. Authors with expertise in these topics are invited to submit their original manuscripts and review articles to Processes.



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# Special Issue



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## Message from the Editor-in-Chief

*Processes* (ISSN 2227-9717) provides an advanced forum for process/system-related research in chemistry, biology, material, energy, environment, food, pharmaceutical, manufacturing and allied engineering fields. The journal publishes regular research papers, communications, letters, short notes and reviews. Our aim is to encourage researchers to publish their experimental, theoretical and computational results in as much detail as necessary. There is no restriction on paper length or number of figures and tables.

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